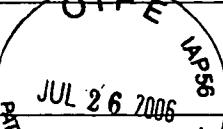


INFORMATION DISCLOSURE CITATION		ATTY. DOCKET NO. <u>4662-182</u>	SERIAL NO. <u>10/578,265</u>
 APPLICANT <u>JAHROMI et al</u>			
(Use several sheets if necessary)	FILING DATE	TC/A.U.	
	<u>July 3, 2006</u>	Unassigned	

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

						TRANSLATION	
DOCUMENT		DATE	COUNTRY	CLASS	SUBCLASS	YES	NO
	10340846	12/22/1998	JAPAN				
	627,719	08/15/1949	GB				
	2005/006026 A2	01/20/2005	PCT				
	1 522 894 A2	04/13/2005	EP				
	2005/024325 A2	03/17/2005	PCT				
	0 023 231 A1	02/04/1981	EP				
	00/06495	02/10/2000	PCT				
	0 967 513 A1	12/29/1999	EP				

OTHER DOCUMENTS (including Author, Title, Date, Pertinent pages, etc.)

European Search Report	5/2004
International Search Report	1/2005
M ROTHSCHILD et al; "Fluorine – an enale in advanced photolithography"; Journal of Fluorine Chemistry; vol. 122; no. 1; July 1 2003; pages 3-10	

***Examiner**

/Brittany Raymond/

Date Considered

03/27/2008

Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to application.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /B.B./

Form PTO-FB-A820 (Also PTO/SB/08A)